# Amendments to the Claims

# **CLAIMS**

1. A process for preparing a compound of the formula (VII)

comprising Step 1A:

contacting a compound of the formula (I)

$$Z \cdot HN \qquad R_2 \qquad R_3 \qquad O \qquad (I)$$

with a base in a suitable solvent to form the free base of compound (I), i.e., compound (II) of the formula (II)

followed by Step 1B:

contacting compound (II) with a strong nucleophile/weak base in a suitable solvent under conditions to form compound (III) of the formula (III)

$$\begin{array}{c|c}
 & R_4 \\
 & R_5 \\
 & R_3 \\
 & O
\end{array}$$
OH
(III)

followed by Step 2A:

contacting compound (III) with a formulating agent in a suitable solvent under conditions suitable to form a compound of formula (IV)

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followed by Step 2B:

contacting compound (IV) with an amine or an alkaline metal hydroxide in a suitable solvent under conditions to form a compound of formula (V)

OHC 
$$R_4$$
  $R_5$  OH  $G$   $V$ 

followed by Step 3:

contacting compound (V) with a compound of formula (VI)

$$\begin{array}{c} X \\ (CH_2)_n \\ S \\ NH-R_1 \end{array}$$
 (VI)

in the presence of a suitable base and one or more coupling agents in a suitable solvent under conditions to form a compound of formula (VII)

### wherein

Y is a hydroxy protecting group;

each of  $R_2$ ,  $R_3$ ,  $R_4$  and  $R_5$  is, independently, hydrogen or alkyl, or ( $R_2$  and  $R_3$ ) and/or ( $R_4$  and  $R_5$ ) collectively form a  $C_{4-7}$ cycloalkyl;

G is -O<sup>e</sup>metal<sup>e</sup> or -OH•amine;

X is  $-CH_{2^-}$ ,  $-S_-$ ,  $-CH(OH)_-$ ,  $-CH(OR)_-$ ,  $-CH(SH)_-$ ,  $-CH(SR)_-$ ,  $-CF_{2^-}$ ,  $-C=N(OR)_-$  or  $-CH(F)_-$ ; R is alkyl;

R<sub>1</sub> is aryl or heteroaryl;

Z is a strong organic or inorganic acid; and n is 0-3, provided that when n is 0, X is -CH<sub>2</sub>-.

2. The process of Claim 1 followed by Step 4, contacting the compound of formula VII, wherein  $R_1$  is heteroaryl having an N heteroatom, with an oxidizing agent to form the corresponding N-oxide derivative.

3. The process of Claim 2 followed by the additional step of removing the hydroxyl protecting group of compound VII to form the compound of formula VIII:

$$\begin{array}{c|c} HO & R_4 & R_5 & X \\ \hline \\ N & R_2 & R_3 & O \\ \hline \\ O & NH-R_1 \end{array}$$
 (VIII)

wherein  $R_1$ ,  $R_2$ ,  $R_3$ ,  $R_4$ ,  $R_5$ , X and n are as defined above.

4. The process of Claim 1,

wherein

each of R2, R3 and R5 is hydrogen;

R<sub>4</sub> is butyl;

X is -CH<sub>2</sub>-;

n is 1;

Y is benzyl or t-butyldimethylsilyl; and

R<sub>1</sub> is of the formula

wherein

R<sub>6</sub> and R<sub>9</sub> are hydrogen;

R<sub>7</sub> is hydrogen or C<sub>1-7</sub>alkyl; and

R<sub>8</sub> is hydrogen, halogen or C<sub>1-7</sub>alkyl.

5. The process of Claim 4,

wherein

R<sub>7</sub> is hydrogen; and

R<sub>8</sub> is fluoro.

6. The process of claim 1, wherein  $R_1$  is of the formula (XIa)

$$\begin{array}{c|c}
R_8 & & \\
\hline
R_7 & & \\
R_8 & & \\
\end{array}$$
(XIa)

each of R<sub>2</sub>, R<sub>3</sub> and R<sub>5</sub> is hydrogen;

R<sub>4</sub> is butyl; X is -CH<sub>2</sub>-; n is 1; Y is benzyl or t-butyldimethylsilyl; R<sub>6</sub> and R<sub>9</sub> are hydrogen; R<sub>7</sub> is hydrogen or C<sub>1-7</sub>alkyl; and R<sub>8</sub> is hydrogen, halogen or C<sub>1-7</sub>alkyl.

- 7. The process of Claim 6 wherein R<sub>8</sub> is halo or ethyl.
- 8. The process of Claim 6 wherein  $R_7$  is hydrogen and  $R_8$  is fluoro.
- 9. The process of Claim 1 wherein

for Step 1A the temperature is about 10° C to about 40° C, the water soluble base is sodium carbonate, sodium bicarbonate, potassium carbonate, potassium bicarbonate, or an alkaline metal hydroxide, and the solvent is water/ethyl acetate,

for Step 1B the temperature is about -10° C to about 10° C, the strong nucleophile/weak base is lithium hydroperoxide, and the solvent is THF/water,

for Step 2A the temperature is about -20° C to about 20° C, the formyalting agent is formic acetic anhydride, and the solvent is ethyl acetate,

for Step 2B the temperature is about -5° c to about 40° C, the solvent is heptane and the G substituent is of the formula -OH•amine wherein the amine is dicyclohexylamine,

for Step 3 the temperature is about 10° C to about 40° C th solvent is water/ethyl acetate, and the coupling agent is EDCI/HOBt, and

for Step 4 the temperature is about 10° C to about 35° C, the solvent is ethyl acetate and the oxidizing agent is urea/hydrogen peroxide with phthalic anhydride or magnesium monoperoxyphthalate.

# 10. A process comprising

contacting a compound of the formula:(I)

$$Z \cdot HN \xrightarrow{R_4} \xrightarrow{R_5} N \xrightarrow{Q} (I)$$

with a base in a suitable solvent to form compound (II) of formula

#### wherein

Y is a hydroxy protecting group;

each of R₂, R₃, R₄ and R₅ is, independently, hydrogen or alkyl, or (R₂ and R₃) and/or (R₄ and R₅) collectively form a C₄-₂cycloalkyl; and Z is a strong organic or inorganic acid.

# 11. A process comprising contacting compound (II) of the formula

with a strong nucleophile/weak base in a suitable solvent under conditions to form compound (III) of the formula

$$\begin{array}{c|c}
HN \\
R_2 \\
R_3
\end{array}$$
OH
(III)

# wherein

Y is a hydroxyprotecting group; and

each of  $R_2$ ,  $R_3$ ,  $R_4$  and  $R_5$  is, independently, hydrogen or alkyl, or ( $R_2$  and  $R_3$ ) and/or ( $R_4$  and  $R_5$ ) collectively form a  $C_{4-7}$ cycloalkyl.

#### 12. A process comprising

contacting compound (III) of the formula

with a formulating agent in a suitable solvent under conditions suitable to form a compound of formula (IV)

$$\begin{array}{c|c}
OHC & R_4 & R_5 \\
N & R_2 & R_3 & OH
\end{array}$$
(IV)

wherein

Y is a hydroxy protecting group; and

each of  $R_2$ ,  $R_3$ ,  $R_4$  and  $R_5$  is, independently, hydrogen or alkyl, or ( $R_2$  and  $R_3$ ) and/or  $R_4$  and  $R_5$ ) collectively form a  $C_{4-7}$ cycloalkyl.

# 13. A process comprising

contacting compound (IV) of the formula

$$\begin{array}{c|c}
OHC \\
N \\
R_2 \\
R_3
\end{array}$$

$$OH \qquad (IV)$$

with an amine or an alkaline metal hydroxide in a suitable solvent under conditions to form a compound of formula (V)

wherein

Y is a hydroxy protecting group;

each of  $R_2$ ,  $R_3$ ,  $R_4$  and  $R_5$  is, independently, hydrogen or alkyl, or ( $R_2$  and  $R_3$ ) and/or ( $R_4$  and  $R_5$ ) collectively form a  $C_{4-7}$ cycloalkyl; and

G is -O<sup>θ</sup>metal<sup>⊕</sup> or –OH•amine.

#### 14. A process comprising

contacting compound (V) of the formula

OHC 
$$R_4$$
  $R_5$   $OH \cdot G$  (V)

with a compound of formula (VI)

$$\begin{array}{c} X \\ NH - R_1 \end{array}$$
 (VI)

in the presence of a suitable base and one or more coupling agents fin a suitable solvent under conditions to form a compound of formula (VII)

$$\begin{array}{c|c}
O & H & R_4 & R_5 & X \\
Y - O - N & R_2 & R_3 & O & N - R_1 \\
\hline
N & N - R_1 & H
\end{array}$$
(VIII)

### wherein

Y is a hydroxy protecting group;

each of  $R_2$ ,  $R_3$ ,  $R_4$  and  $R_5$  is, independently, hydrogen or alkyl, or ( $R_2$  and  $R_3$ ) and/or ( $R_4$  and  $R_5$ ) collectively form a  $C_{4-7}$ cycloalkyl;

G is -O<sup>e</sup>metal<sup>⊕</sup> or -OH•amine;

X is -CH<sub>2</sub>-, -S-, -CH(OH)-, -CH(OR)-, -CH(SH)-, -CH(SR)-, -CF<sub>2</sub>-, -C=N(OR)- or- CH(F)-; R is alkyl;

R<sub>1</sub> is aryl or heteroaryl; and

n is 0-3, provided that when n is 0, X is -CH<sub>2</sub>-.